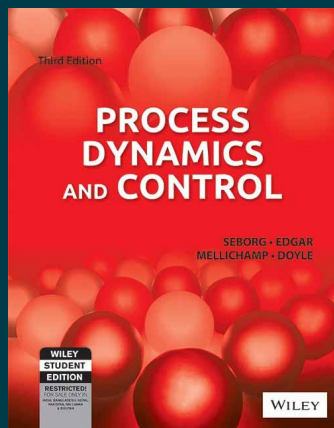


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## Process Dynamics and Control, 3ed, ISV

By Seborg, Edgar, Mellichamp, Doyle

**Paperback**

ISBN: 9788126541263

Publication: [ NOT PROVIDED ] *publication\_date*

Page Count: 464 pages

**₹889.00**

### • Description

This third edition provides chemical engineers with process control techniques that are used in practice while offering detailed mathematical analysis. Numerous examples and simulations are used to illustrate key theoretical concepts. New exercises are integrated throughout several chapters to reinforce concepts. Up-to-date information is also included on real-time optimization and model predictive control to highlight the significant impact these techniques have on industrial practice

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